Initial Information Data Sheet

Inventor Information

Inventor One Given Name:

Family Name: Name Suffix:

Postal Address Line One Postal Address Line Two

City:

State or Province: Postal or Zip Code: Citizenship Country:

Inventor Two Given Name:

Family Name:

Name Suffix:

Postal Address Line One Postal Address Line Two

City:

State or Province: Postal or Zip Code: Citizenship Country:

Inventor Three Given Name:

Family Name:

Name Suffix:

Postal Address Line One Postal Address Line Two

City:

State or Province: Postal or Zip Code: Citizenship Country: Hiroshi

YASUDA

c/o ADVANTEST CORPORATION

1-32-1 Asahi-cho, Nerima-ku

Tokyo Japan 179-0071 Japan

Shinichi

HAMAGUCHI

c/o ADVANTEST CORPORATION

1-32-1 Asahi-cho, Nerima-ku

Tokyo Japan 179-0071 Japan

Takeshi

HARAGUCHI

c/o ADVANTEST CORPORATION

1-32-1 Asahi-cho, Nerima-ku

Tokyo Japan 179-0071 Japan

Correspondence Information

Name Line One:

Name Line Two:

Address Line One: Address Line Two:

Citv:

State or Province: Postal or Zip Code:

Fax:

Telephone:

Electronic Mail:

David L. Fehrman

Morrison & Foerster LLP

555 W. 5th Street

35th Floor Los Angeles California 90013

213-892-5601 213-892-5454

DFehrman@mofo.com

Application Information

Title Line One:
Title Line Two:
Title Line Three:
Title Line Four:

Total Drawing Sheets: Formal Drawings?:

Application Type: Docket Number:

SEMICONDUCTOR DEVICE MANUFACTURING SYSTEM AND ELECTRON BEAM EXPOSURE APPARATUS

8 Yes

Non-provisional 514802001100

Representative Information

Representative Customer Number:

25224

PATENT TRADEMARK OFFICE

Continuity Information

This application is a: > Application One: Filing Date:

which is a:

>>Application Two:

Filing Date:

which is a:

>>>Application Three:

Filing Date:

Prior Foreign Applications

Foreign Application One:

Filing Date: Country:

Priority Claimed:

2000-304245 October 3, 2000

Japan Yes

Assignee Information

Assignee:

ADVANTEST CORPORATION